



INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

September 10, 2026

IGI Report Number
Description
Shape and Cutting Style
Measurements

LG836628897
LABORATORY GROWN DIAMOND
ROUND BRILLIANT
8.69 - 8.77 X 5.26 MM

GRADING RESULTS

Carat Weight
Color Grade
Clarity Grade
Cut Grade

2.51 CARATS
F
VVS 2
EXCELLENT

ADDITIONAL GRADING INFORMATION

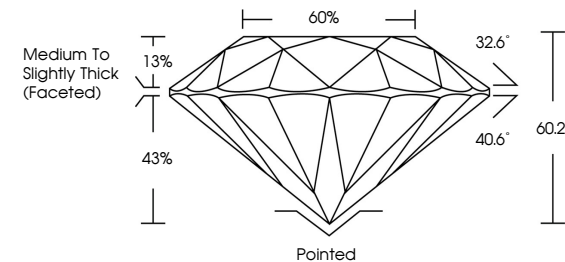
Polish
Symmetry
Fluorescence
Inscription(s)

EXCELLENT
EXCELLENT
NONE
IGI LG836628897

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
Type IIa

Report verification at igi.org

PROPORTIONS



Medium To Slightly Thick (Faceted)

60%

32.6°

40.6°

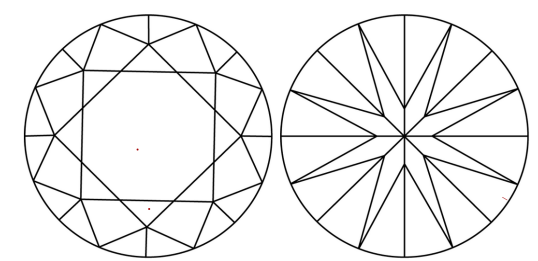
60.2%

43%

13%

Pointed

CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.

COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VVS 1-2 VS 1-2 SI 1-2 I 1-3

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

Sample Image Used



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IGI



September 10, 2026
IGI Report No LG836628897
ROUND BRILLIANT
8.69 - 8.77 X 5.26 MM
Carat Weight
Color Grade
Clarity Grade
Depth
Table
Girdle
Culet
Polish
Symmetry
Fluorescence
Inscriptions(s)

2.51 CARATS
F
VVS 2
EXCELLENT
60.2%
65%
Medium To Slightly Thick (Faceted)
Pointed
EXCELLENT
EXCELLENT
NONE
IGI LG836628897

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.
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www.igi.org

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